

Laser techniques for advanced accelerator researches:

# EO sampling technique for femtosecond beam characterization

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# Outline

# • Motivation

The need for ultrafast beams Tradition techniques

# • Current EO Technique and limitation

Mechanism Characteristics Current status and limitation

• A phantom experiment and the FROG tech The phantom and the method The experiment plan



## The need for ultrafast beams





## Some of the methods

#### **INVASIVE**

#### •**RF** zero phasing

Wang et al, Phys. Rev. E 57, 2283–2286 (1998)

#### •Beam tomography

Yakimenko et al., PRSTAB 6, 122801 (2003)

#### **NON-INVASIVE**

#### •Coherent radiation transition

Lumpkin et al., PRL 88, 234801 (2002)

#### •Streak camera

Lumpkin et al., PRL 82, 3605 (1999)

#### MISC

#### •Compton scattering

Leemans, PRL 77, 4182 (1996)

#### •Spectrum statistics

Catravas, PRL 82, 5261 (1999)

Limited by rf voltage and frequency Complexity in the energy distribution Multiple shots

Beam profile is assumed not measured

Multiple shot, time resolution at 1 ps

Complexity set up Multiple shots

**Multiple shots** 

**High spectrum resolution** 



## **EO Sampling technique: Pockel's effect (ZnTe)**





## **Progress in time resolution**

#### Impact of Optics on Ultrafast Electronics





# The field traveling with the beam





For a single charge q with  $v=\beta c$ :

$$\vec{E} = \frac{q\vec{R}}{4\pi\varepsilon_0 R^3\gamma^2 (1-\beta^2\sin^2\psi)^{3/2}}.$$

For a line charge density q(t) and  $\gamma >>1$ :

$$E_r(t) = \frac{q(t)}{2\pi\varepsilon_0 r}.$$



# **Past EO e-beam measurements**

### Fermi lab

Fitch et al, Proc Linac 2000, 155 (2000). Unsuccessful in generating bunch info

## Brookhaven

Y. K. Semertzidis et al. *Proceedings PAC'99*, 490 (1999). 100 ps resolution.

## FELIX

Yan et al., Phys. Rev. Lett. 85, 3404 (2000); Wilke et. al., Phys. Rev. Lett. 88, 124801 (2002). 2-ps resolution.

#### Other institution (SPPS, DUV-FEL, GTF) Trying .....



## **The FELIX experiment: chirped probe pulse**





• Fundamental limitation: crystal response

Thickness related, for 0.1 mm crystals ZnTe: 5 THz; GaP: 9 THz: limited at 100 fs.

• Fundamental limitation: bandwidth of the probe laser

 $\Delta t \approx \sqrt{\sigma_t T}.$ where  $\sigma_t \sim 1/\sigma_{\omega}$ . For  $\sigma_t = 100$  fs, T=100 ps,  $\Delta t \approx 3$  ps.

- Geometry limitation: beam energy and distance  $\Delta t = r/c\gamma$ . For APS,  $\gamma = 14000$ , with r=1cm,  $\Delta t = 2$  fs
- Instrumental limitation: spectral resolution



# **Crystal properties**





# Some formula

The probe pulse

$$E_{pin}(t) = \exp\left[-\frac{1}{2}\left(\frac{t}{T}\right)^2 - i\left(\omega + \frac{\sqrt{4T^2\Delta\omega^2 - 1}}{4T^2}t\right)t\right].$$

Given, electron beam field, E(t) in the time domain and  $E(\omega) = F[E(t)]$  in the frequency domain, and the complex response function  $G(\omega)$ , in the FELIX exp, one measured

$$I_{pout}(\omega) = \left| F[E_p \cdot F^{-1}(E \cdot G)] \right|^2$$

The other possibility is to do a different measurement, to get

$$E_{pout}(t) = E_{pin}(t) \cdot E(t) * G(t).$$

## Which is equivalent to intensity +phase.



# How about a FROG?





## **Sample traces: FEL experiment**





# **APS Experimental goal and setup**

## Key features

- Use laser-generated THz radiation as an electron beam phantom, in a lab setting
- Employ the Frequency-Resolved Optical Gating (FROG) for <u>single-shot fs</u> <u>resolution</u>

## Goal





# Lab

Bandwidth	<b>16 nm</b>
<b>Pulse duration</b>	<b>70 fs</b>
Rep Rate	1 kHz
Energy	~ mJ





## Plan

## Generating the phantom Optical rectification

Z. Jiang and X. C. Zhang, IEEE J. Quantum Electron. 36, 1214 (2000). H. J. Bakker et al., JOSA B 15, 1795 (1998).

A. Leitenstorfer et al., APL 74, 1516 (1999).

## Probing the phantom EO sampling + FROG Try different crystals Try different laser pulses

**Application in the lab?**